Fabrication of Sm-Based Perovskite-Type Oxide Thin-Films and Gas Sensing Properties to Acetylene

Tomohisa Tasaki, Satoko Takase, Youichi Shimizu*
Department of Applied Chemistry, Kyushu Institute of Technology, Tobata, Japan
Email: *shims@tobata.isc.kyutech.ac.jp

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ABSTRACT
Sm-based perovskite-type oxide (SmMeO₃: Me = Cr, Mn, Fe, Co) thin-films could be synthesized by a wet-chemical method using an acetylacetone—Poly(Vinyl Pyrrolidone) (PVP) polymeric precursor method at 750°C. The perovskite-type oxide thin-films were tried to apply an acetylene gas sensor based on AC impedance spectroscopy. Among the oxides tested, SmFeO₃ thin-film sensor showed good sensor responses in which the AC impedance at 20 kHz was depending on acetylene gas concentration between 2 ppm and 80 ppm at 400°C.

Keywords: Perovskite-Type Oxide; Thin-Film; Ac Impedance; Acetylene; Gas Sensor

1. Introduction
Lanthanoid-based perovskite-type oxides, such as LnMeO₃ (Ln: lanthanoids, Me: transition metals), have been well-known as functional inorganic materials having a wide range of applications for electrode materials of the alkaline fuel cell [1], gas sensor [2-10], ion sensor [11], and for high-performance catalysts for the complete oxidation of hydrocarbons or CO, and NO reduction [12]. Among the lanthanoid-transition metal perovskite-type oxides, Sm-based oxides seem to be interesting materials as they have the largest amount of adsorbed oxygen [13]. For example, the Sm-based perovskite-type oxide sensors have been reported to detect NOₓ [14], volatile organic compounds [15], ethanol [16] and so on. It is also well-known that the oxide thin-film devices have good properties as electrochemical devices. So far, oxide thin-film with a perovskite-type structure have been prepared by dry processes such as sputtering and electron-beam deposition methods [17,18], as well as the wet processes of the sol-gel method mainly starting from metal alkoxides or organic acid salts [19,20]. They can field high-quality oxide thin-films; however, they still have some problems, such as relatively low cost performance and lack of handling of the chemicals using the sol-gel method. Consequently, in this work it is focused attention on a wet process to evade such problem, and perovskite-type oxide could be synthesized by a polymer precursor with metal nitrates contained constituent elements [21,22]. By the way, acetylene (C₂H₂) is widely used as the fuel for cutting and welding metals, so there are also strong needs to detect acetylene as combustible gas. Recently, it has known that small amount of acetylene is to be generated from depleted insulating oils of an oil-immersed transformer. Thus, the acetylene gas sensor could be applicable as a new type of maintenance’s marker of the transformers, especially for the large sized transformers set in remote areas.

The conventional chromatographic method for acetylene detection has high accuracy and is widely used, but it is not suitable for on-site monitoring because of the limited portability as well as the high operating cost. So far, considerable efforts have been directed to develop high performance gas sensors for monitoring acetylene, such as electrochemical sensors [23], and semiconductor type sensors [24,25], however, the sensor for detection acetylene have been seldom reported.

In this study, the Sm-based perovskite-type oxide thin-film as the material of an acetylene sensor was picked up and systematically evaluated about wet-chemical synthesis of perovskite-type oxide thin-film [26] and the C₂H₂ sensing properties of the prepared oxide thin-film.

2. Experimental

2.1. Synthesis of Perovskite-Type Oxide Thin-Films
Perovskite-type oxide (SmMeO₃: Me = Cr, Mn, Fe, Co) thin-films were synthesized by a polymer precursor method [26] as shown in Figure 1. Metal nitrates were dissolved in Ethylene Glycol (EG) solvent with Polyvinylpyrrolidone (PVP) (3.75 wt%) and acetylacetone (AcAc), as a polymer additive and a coordination agent,
respectively. The solution thus prepared was spin-coated on an alumina substrate with Au interdigitated electrodes at 4000 rpm, and finally sintered at 750°C in air. The spin-coating and sintering processes were repeated several times to adjust the thickness.

The samples were analyzed by X-ray diffraction using CuKα radiation (XRD: JEOL JDX3500K), field emission type scanning electron microscope (FE-SEM: JEOL JSM-6500F/III), and thermo gravimetric-differential thermal analysis (TG-DTA: Rigaku 8120H). Electrical conductivities of the thin-films were measured in air (PO₂ = 0.21 atm) at the temperature range between 200°C and 500°C in the frequency range from 50 Hz to 5 MHz with applied voltage of 0.5 V by AC impedance method (LCR meter: HIOKI 3532-50).

2.2. Fabrication of Sensor Devices

Figure 2 shows schematic diagram of the measurement apparatus. The perovskite-type oxide thin-film sensor device was connected to LCR meter with Au lead wires attached with a silver paste covered with an inorganic adhesive. Gas sensing properties were investigated by AC impedance method using the LCR meter at 400°C - 500°C. Sample gases, containing C₂H₂ were prepared from a parent gas, i.e., 2 - 80 ppm C₂H₂ diluted with nitrogen, by mixing with nitrogen and/or oxygen, were flowed at a total flow rate of 100 cm³/min. The oxygen partial pressure of the sample gases was fixed at 0.21 atm. Sensitivities of the responses of the sensors were defined as Equation (1);

\[ S_{R,C} \% = \frac{R_{gas} - R_{air}}{R_{air}} \times 100 \] (1)

Figure 3 shows XRD patterns of the SmMeO₃ (Me = Cr, Mn, Fe, Co) thin-films prepared at 750°C by the polymer precursor method on an Al₂O₃ substrate with Au electrode. XRD patterns of the thin-films consisted of perovskite-type oxide phase, Al₂O₃ and Au peaks from...
3.2. Gas Sensing Properties

For investigate the impedance responses of the sensor devices, the dependence of frequency response on C₂H₂ concentration in air (P(0₂) = 0.21 atm) of the sensor devices were firstly measured from 50 Hz to 5 MHz at the temperature range between 400°C and 500°C. Figure 6 shows Nyquist’s plots of the SmFeO₃ thin-film device in air and 80 ppm C₂H₂ at 400°C. Although the few disarray plots at lower frequency were observed, the Nyquist’s plots showed good-looking semicircles. The increase in resistance change with increasing C₂H₂ concentration was observed especially at around 20 kHz which seems to be come from the grain boundary characteristics as shown by equivalent circuits. Moreover, the frequency responses from boundaries between intraparticle and grain boundary were lower by frequency-shifted with the substrate.

SEM images of the SmMeO₃ (Me = Cr, Mn, Fe, Co) thin-films with 3 times spin-coatings were shown in Figure 5. The surface of the SmFeO₃ thin-film prepared at 750°C was relatively smooth and consisted of homogeneous fine grains of dimension approximately 30 nm, and thickness of the film was ca. 220 nm. The SmMnO₃ and SmCoO₃ thin-films showed similar characteristics, although the grain size was as large as 50 - 100 nm. The SmCrO₃ thin-film however showed more large grain-size and thickness of the film was ca. 440 nm.

Figure 3. TG-DTA curves of the Sm-Co xerogel powder in air until 1000°C (10°C/min).

Figure 4. XRD patterns of the perovskite-type oxide Sm-MeO₃ (Me = Cr, Mn, Fe, Co) and LaFeO₃ thin-films. (a) SmCoO₃ (25-1071); (b) SmFeO₃ (39-1490); (c) SmMnO₃ (25-0747); (d) SmCrO₃ (08-0169); (e) LaFeO₃ (37-1493).

Figure 5. SEM images of the perovskite oxide thin-films on an Al₂O₃ substrate with 3 times spin-coatings; (a) SmCrO₃; (b) SmMnO₃; (c) SmFeO₃; (d) SmCoO₃.

Figure 6. Nyquist’s plots and the equivalent circuits for the SmFeO₃ thin-film device in air and 80 ppm at 400°C.
increasing C2H2 concentration. Response characteristics of the SmFeO3 and SmCoO3 thin-film devices to C2H2 at 20 kHz, 400°C are shown in Figures 7 and 8, respectively. The resistance and the capacitance components were divided from the complex impedancemetric measurement. The capacitance responses of both devices showed no response. Although the SmCoO3 thin-film device showed no resistance response at all, it was found that SmFeO3 thin-film device showed excellent resistance sensor response with good response and recovery rates. As the Fe-doped perovskite-type oxide thin-film device showed the resistance response, the surface adsorption and/or reaction of C2H2 on the oxide seems to be unique and important. C2H2 adsorption on oxides should cause the change-transfer in the oxides, which affect the change in resistance as well as capacitance of the oxides. Little capacitance change of the sensor device might be come from the sensor structure, such as the thickness of the oxide and the physical strucure of the Au-electrodes. The resistance responses of the SmFeO3 device to various concentration of C2H2 at 400°C - 500°C were shown in Figure 9. The responses of SmFeO3 device was decreased with increasing operating temperature from 400°C to 500°C. This seems come from the p-type semi-conductive property and the coverage of oxygen ions of the perovskite-type oxides, because the adsorbed oxygen ions are reduced by reduction reaction on the surface with causing the release of electrons in the perovskites [27-29].

Table 1 summarizes the sensitivities of the SmMeO3 (Me = Cr, Mn, Fe, Co) thin-film devices to 10 ppm C2H2 at 400°C - 500°C. Unlike the response of the SmFeO3 device, the SmCoO3, SmCrO3 and SmMnO3 C2H2 concentrations / ppm

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<th>SmCrO3</th>
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*Gas concentration of C2H2 and C2H4 is 5 ppm and 50 ppm, respectively.

**Sensitivity Sd[\%] = \frac{R_\text{d} - R_\text{n}}{R_\text{n}} \times 100 .
devices seldom showed apparent response to low concentration of C\textsubscript{2}H\textsubscript{2} at the operating temperatures. One of the results would be expressed that surface-controlled gas sensor based oxide semiconductor is to be high conductivity by increasing working temperature. In details, the sensitivities were decreased because the change of surface conductivity with chemical reaction on oxide surface is relatively small for high bulk conductivity even if the oxide device is reacted to same C\textsubscript{2}H\textsubscript{2} concentration.

For investigating the electrical properties of the prepared oxide thin-films, the conductivities was determined from Arrhenius equation in air at the temperature range between 200$^\circ$C and 500$^\circ$C in the frequency range from 50 Hz to 5 MHz with applied voltage of 0.5 V by AC impedance method as shown in Figure 10. The conductivities $\sigma$ [S/cm\textsuperscript{-1}] of all thin-films were calculated from their real part impedance ($Z'$) corresponding to the minimum of their imaginary part ($Z''$) as shown in Figure 6.

The prepared thin-films represented an increased conductivity with increasing operating temperature, which has a typical semiconductor behavior. Although the SmCrO\textsubscript{3} and SmFeO\textsubscript{3} thin-films seldom showed low conductivity below 300$^\circ$C, the SmMnO\textsubscript{3} and SmCoO\textsubscript{3} thin-films showed still high conductivity below 300$^\circ$C. And also, large difference of the conductivities between SmFeO\textsubscript{3} and SmCoO\textsubscript{3} over the operating temperature range. Additionally, the activation energies of the films exhibited smaller than 1 except for the SmFeO\textsubscript{3}. Consequently, the SmMnO\textsubscript{3} and SmCoO\textsubscript{3} with a high conductivity and low activation energy would make it cause to react with a detection gas on their quite surface. As the variant condition of film formation and film thickness, the results showed a similar leaning with the La-based perovskite thin-film reported Ngamou et al. and occurred the charge transfer (Me\textsuperscript{4+} ↔ Me\textsuperscript{3+}) via the Me-O-Me bonds [30].

Figure 11 shows the selectivity of SmFeO\textsubscript{3} thin-film device to interference gases such as 80 ppm C\textsubscript{2}H\textsubscript{2}, 80 ppm C\textsubscript{2}H\textsubscript{4}, 80 ppm C\textsubscript{2}H\textsubscript{6}, 80 ppm C\textsubscript{2}H\textsubscript{5}, and 80 ppm C\textsubscript{2}H\textsubscript{4} at 400$^\circ$C, 20 kHz.

The perovskite-type oxide SmMeO\textsubscript{3} (Me = Cr, Mn, Fe, Co) thin-film sensors could be prepared by a polymer precursor method. The SmFeO\textsubscript{3}-based thin-film device showed good sensing characteristics to C\textsubscript{2}H\textsubscript{2} between 2 and 80 ppm at 400$^\circ$C with 90% response time of ca. 15 sec. Moreover, the sensor device had relatively high sensitivity which showed increasing resistance response to C\textsubscript{2}H\textsubscript{2}.

4. Conclusion

The perovskite-type oxide SmMeO\textsubscript{3} (Me = Cr, Mn, Fe, Co) thin-film sensors could be prepared by a polymer precursor method. The SmFeO\textsubscript{3}-based thin-film device showed good sensing characteristics to C\textsubscript{2}H\textsubscript{2} between 2 and 80 ppm at 400$^\circ$C with 90% response time of ca. 15 sec. Moreover, the sensor device had relatively high sensitivity which showed increasing resistance response to C\textsubscript{2}H\textsubscript{2}.

REFERENCES


